

1/5

+

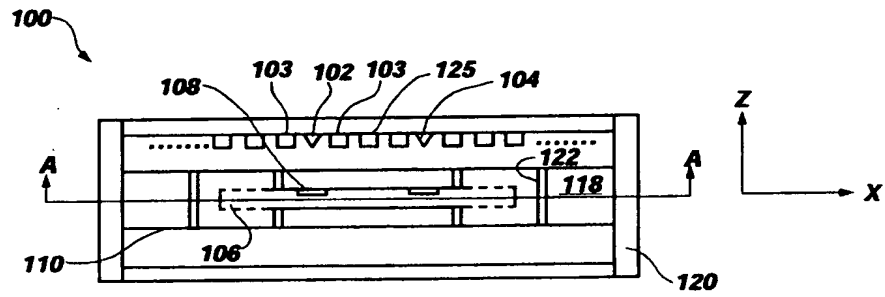


FIG. 1

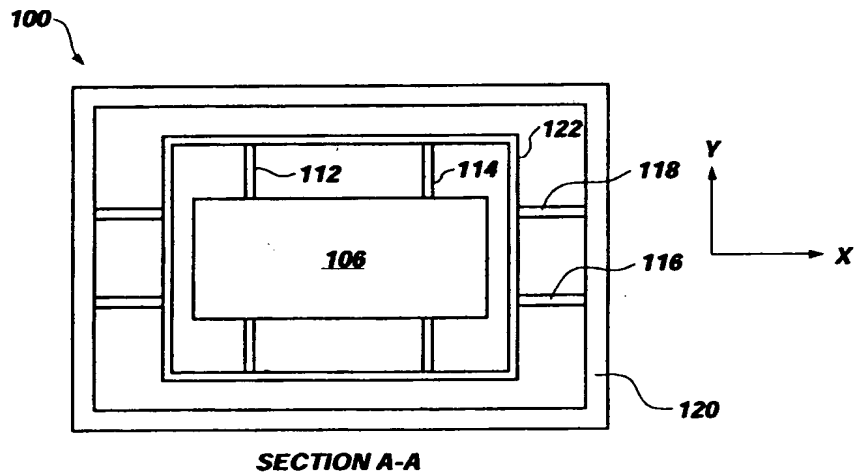


FIG. 2

2/5

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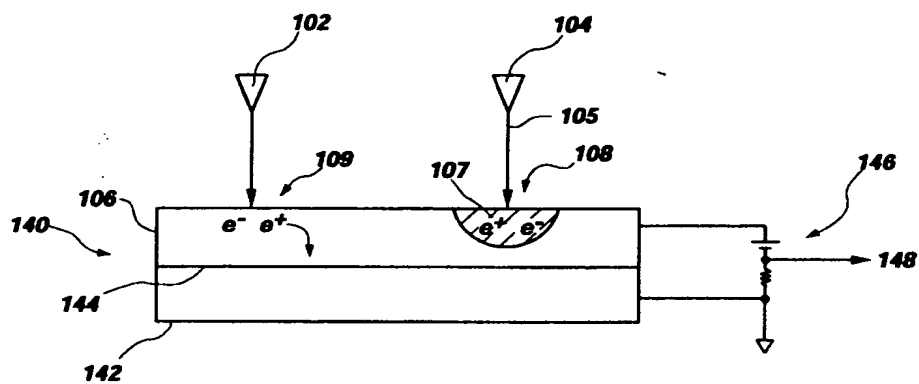


FIG. 3

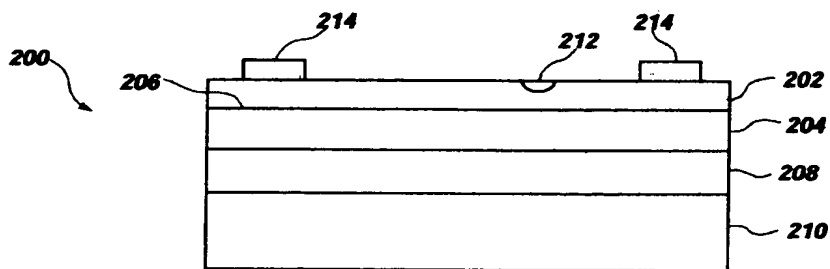


FIG. 4

3/5

300
↓

310

SELECT A SUBSTRATE

312

FABRICATE A FIELD LAYER ON THE SUBSTRATE

314

FABRICATE A SECOND DIODE LAYER OF DIODE MATERIAL
ON THE FIELD LAYER

316

FABRICATE A FIRST DIODE LAYER OF CIS PHASE-CHANGE
MATERIAL ON THE SECOND DIODE LAYER

318

FABRICATE GRID CONTACTS ON THE FIRST DIODE LAYER

FIG. 5

4/5

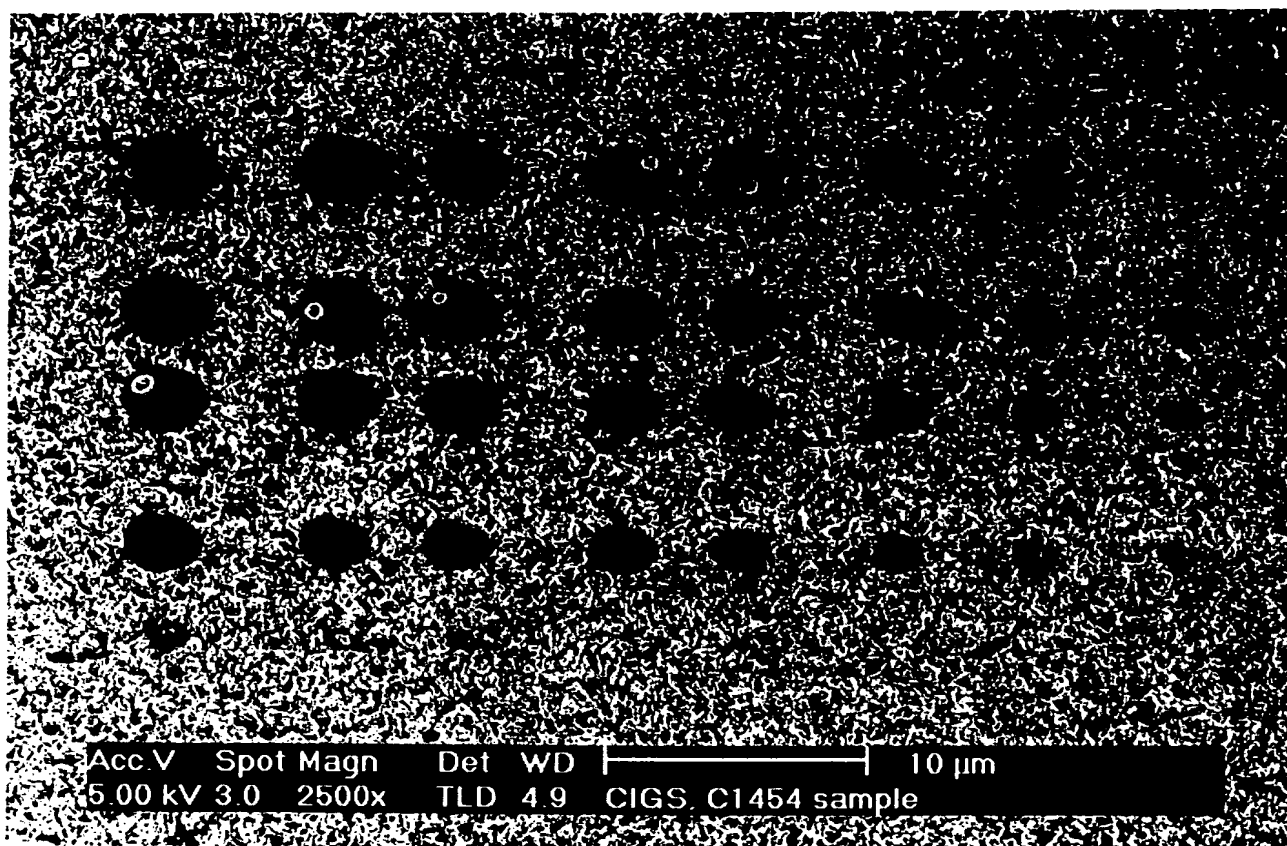


FIG. 6

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5/5

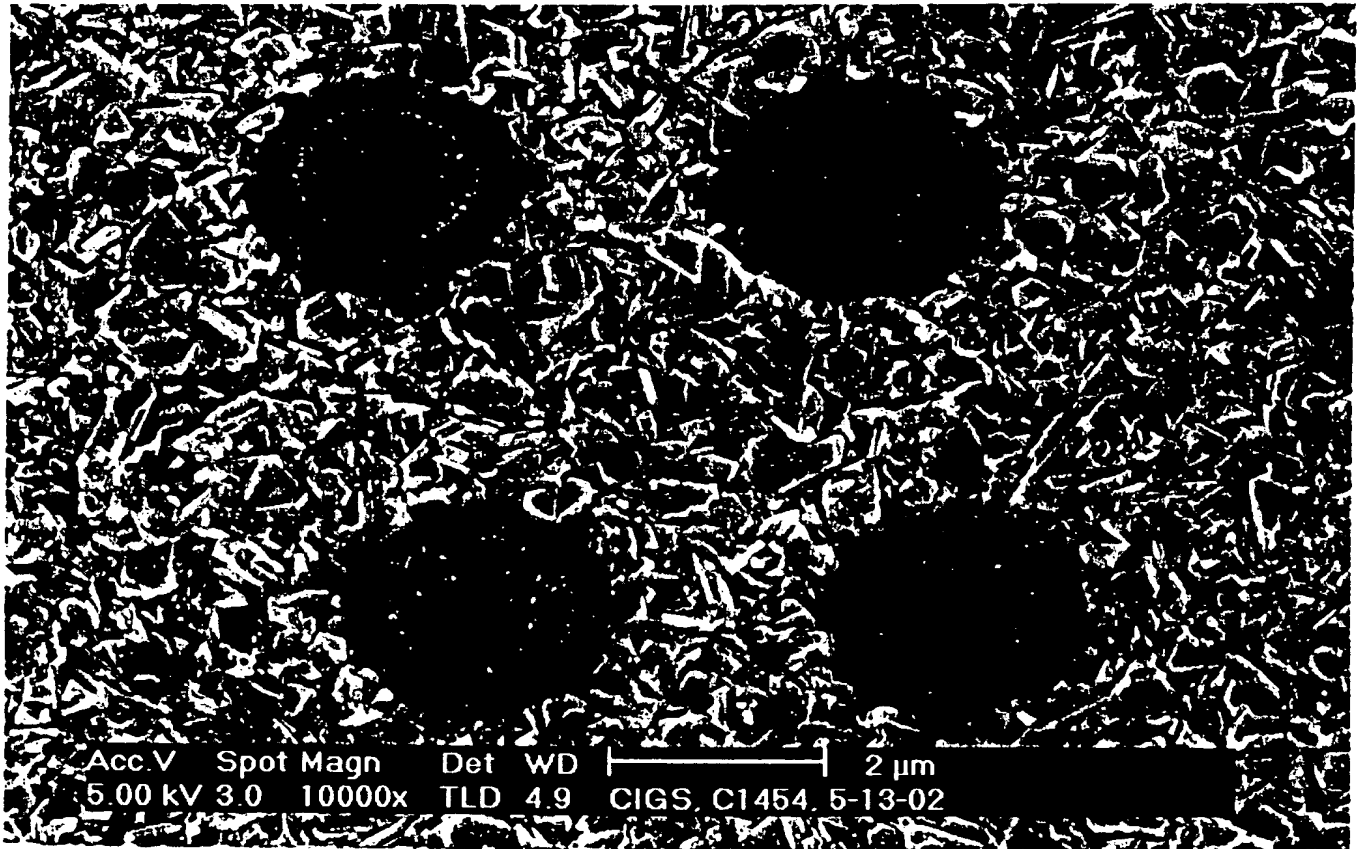


FIG. 7

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